Electronic Supplementary Information (ESI)

Growth of two-dimensional rhenium disulfide (ReS₂) nanosheets with a few layers at low temperature

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Fig. S1



Fig. S1 The temperature dependence of the growth for the ReS₂ nanosheets under the flow of He carrier gas of 10 sccm for 20 minutes: (a) 350°C, (b) 400°C, (c) 450°C, (d) 500°C, (e) 550°C, and (f) 600°C, respectively.

Fig. S2



Fig. S2 X-ray photoelectron survey spectrum for the ReS_2 nanosheets grown at 450°C under the flow of He carrier gas of 10 sccm for 20 minutes.

Fig. S3



Fig.	S3	Filtered	Z-contrast	HAADF-STEM	and	the	corresponding	FFT	image	of	ReS ₂
nano	shee	ts	taken	at	[24]	[]	zone		axis		





Fig. S4 Energy dispersive X-ray (EDX) elemental mapping analysis of the ReS₂ nanosheets. (a) HAADF-STEM image, (b) Re L series and (c) S K series.



Element	Line Type	k Factor	k Factor type	Absorption Correction	Wt%	Wt% Sigma	Atomic%
S	K series	0.982		1.00	27.63	0.50	68.91
Re	M series	1.665		1.00	72.37	0.50	31.09
Total					100.00		100.00

Fig. S5 TEM-EDS spectrum for the ReS_2 nanosheets grown at 450°C under the flow of He carrier gas of 10 sccm for 20 minutes.